WHAT IS CLAIMED IS:

- 1. A method for modifying a portion of a substrate surface, said method comprising:
 - (a) producing a solvent layer on said substrate surface;
- 5 (b) selectively protecting at least one site on said substrate surface with a protective bubble; and
 - (c) contacting said selectively protected substrate surface with a reactive agent under conditions sufficient for said reactive agent to react with unprotected susceptible moieties present said substrate surface;
- whereby a portion of said substrate surface is modified.
 - 2. The method according to Claim 1, wherein said method comprises reiterating steps (b) and (c) at least one additional time.
- 15 3. The method according to Claim 1, wherein said method further comprises removing unreacted reactive agent from said substrate surface following said contact step.
- 4. The method according to Claim 1, wherein said protective bubble is produced 20 by a bubble producing means.
 - 5. The method according to Claim 4, wherein said bubble producing means is a heating means.
- 25 6. The method according to Claim 4, wherein said bubble producing means is a component of said substrate.
 - 7. The method according to Claim 4, wherein said bubble producing means is present on a structure separate from said substrate.
 - 8. A method for synthesizing a plurality of polymers on a substrate surface, said

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method comprising:

- (a) producing a solvent layer on said substrate surface, where said substrate surface has a plurality of individually activatable resistors associated with it;
 - (b) performing at least two iterations of the following steps:

(1) selectively protecting at least one site on said substrate surface with a protective bubble by selective activation of said resistors;

- (2) contacting said selectively protected substrate surface with a reactive agent under conditions sufficient for said reactive agent to react with unprotected susceptible moieties present on said substrate surface; and
- (3) removing unreacted reactive agent from said substrate surface; whereby a plurality of polymers are produced on said substrate surface.
- 9. The method according to Claim 8, wherein said reactive agent is a deblocking agent.
 - 10. The method according to Claim 8, wherein said reactive agent is an activated monomer.
- 20 11. The method according to Claim 8, wherein said polymers are nucleic acids.
 - 12. A method for synthesizing a plurality of polymers on a substrate surface, said method comprising:
 - (a) producing a solvent layer on said substrate surface;
- 25 (b) performing at least two iterations of the following steps:
 - (1) selectively protecting at least one site on said substrate surface with a protective bubble, where said protective bubble is produced by activation of a resistor present on a structure apart from said substrate;

(2) contacting said selectively protected substrate surface with a reactive agent under conditions sufficient for said reactive agent

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to react with unprotected susceptible moieties present on said substrate surface; and

- (3) removing unreacted reactive agent from said substrate surface; whereby a plurality of polymers are produced on said substrate surface.
- 13. The method according to Claim 12, wherein said reactive agent is a deblocking agent.
- 14. The method according to Claim 12, wherein said reactive agent is an activated 10 monomer.
 - 15. The method according to Claim 12, wherein said polymers are nucleic acids.
 - 16. The method according to Claim 12, wherein said polymers are peptides.
 - 17. A substrate produced according to the method of Claim 1.
 - 18. A polymeric array comprising:
- a plurality of distinct polymers stably associated with the surface of a substrate,
 wherein said substrate comprises a plurality of individually activatable resistors
 associated with said surface and at least one of said polymers is associated with at least
 one of said resistors.
- 19. The polymeric array according to Claim 18, wherein said plurality of resistors25 are beneath said surface of said substrate.
 - 20. A nucleic acid array comprising:

a plurality of nucleic acid spots stably associated with the surface of a substrate, wherein said substrate comprises a plurality of individually activatable resistors beneath said surface and at least one of said nucleic acid spots is associated with at least one of said resistors.

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- A kit for producing a polymeric array, said kit comprising:
 a substrate having a plurality of activatable resistors; and
 a deblocking agent.
- 22. The kit according to Claim 21, wherein said kit further comprises a solvent.
- 23. The kit according to Claim 21, wherein said kit further comprises monomeric reagents.
 - 24. A method of detecting the presence of an analyte in a sample, said method comprising:

associated with the surface of a substrate, wherein said substrate comprises a plurality of individually activatable resistors associated with said surface, with (b) a sample suspected of comprising said analyte under conditions sufficient for binding of said analyte to a complementary polymer on said array to occur; and

detecting the presence of binding complexes on the surface of the said array; whereby the presence of said analyte in said sample is detected.

- 25. The method according to Claim 24, wherein said polymer is a nucleic acid.
- 26. The method according to Claim 25, wherein said analyte is a nucleic acid and said binding is by hybridization.
 - 27. The method according to Claim 24, wherein said method further comprises activating at least one of said resistors during at least one of said contacting and detecting steps.

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